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CLAIMS

1. An anisotropic conductive film comprising:

a porous film consisting of polymer, having numerous holes penetrating in a film thickness direction, the holes being in a honeycomb arrangement and having inner wall surfaces which curve outwards;

a conductive material that fills the holes in the porous film; and

an adhesive layer coated on both surfaces of the porous film.

- 2. The anisotropic conductive film according to claim 1, wherein the polymer consists of one or more polymers selected from among polysulfone, polyethersulfone, polyphenylene sulfide, polyimide, polyamide-imide, siloxane-modified polyimide, siloxane-modified polyamide-imide, polyether imide and polyether ether ketone.
- 3. The anisotropic conductive film according to claim 1, wherein the porous film is formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent, a polymer soluble in this organic solvent and an amphiphilic material, in the atmosphere at a relative humidity of 50% or more.
- 4. The anisotropic conductive film according to claim
 1, wherein the porous film and the conductive material
 are formed by leaving a supporting substrate on which

cast is a polymer solution containing at least a hydrophobic, volatile organic solvent, a polymer soluble in this organic solvent, an amphiphilic material and a conductive material, in the atmosphere at a relative humidity of 50% or more.

- 5. The anisotropic conductive film according to claim 3 or 4, wherein the polymer soluble in the organic solvent is one or more polymers selected from among polysulfone, polyethersulfone, polyphenylene sulfide, siloxane-modified polyimide and siloxane-modified polyamide-imide.
- 6. The anisotropic conductive film according to claim 1, wherein the porous film is formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent and an amphiphilic polymer, in the atmosphere at a relative humidity of 50% or more.
- 7. The anisotropic conductive film according to claim 1, wherein the porous film and the conductive material are formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent, an amphiphilic polymer and a conductive material, in the atmosphere at a relative humidity of 50% or more.
- 8. The anisotropic conductive film according to claim 6 or 7, wherein the amphiphilic polymer is a polyionic complex of a polymer having a hydrophobic group

introduced into at least one of a main chain and a side chain, with a cationic lipid.

- 9. The anisotropic conductive film according to claim 6 or 7, wherein the amphiphilic polymer is a polyionic complex of a polyamic acid with a cationic lipid, and the porous film is imidized after film-forming.
- 10. The anisotropic conductive film according to any of claims 1 to 9, wherein a diameter of the holes is smaller than the narrowest gap between plural conductors provided to connection targets, and a gap between the holes is smaller than the narrowest width of the conductors.
- 11. The anisotropic conductive film according to any of claims 1 to 10, wherein the conductive material consists of a group of conductive particles.
- 12. The anisotropic conductive film according to claim 11, wherein the conductive particles are particles of metal.
- 13. The anisotropic conductive film according to claim 12, wherein the metal consists of one or more metals selected from among Ag, Au, Pt, Ni, Cu and Pd.
- 14. The anisotropic conductive film according to claim 12 or 13, wherein a group of the metal particles filling the holes are fusion bonded by heating to be integral.
- 15. The anisotropic conductive film according to any of claims 1 to 14, wherein the adhesive layer is a prepreg wherein a thermosetting resin is in a semi-cured state.

- 16. The anisotropic conductive film according to claim 15, wherein the thermosetting resin is an epoxy resin.
- 17. A method of manufacturing an anisotropic conductive film, comprising the steps of:

forming a porous film consisting of polymer, having numerous holes penetrating in a film thickness direction, the holes being in a honeycomb arrangement and having inner wall surfaces which curve outwards;

filling the holes in the porous film with a conductive material; and

coating both surfaces of the porous film with an adhesive layer.

- 18. The method of manufacturing the anisotropic conductive film according to claim 17, wherein the porous film is formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent, a polymer soluble in this organic solvent and an amphiphilic material, in the atmosphere at a relative humidity of 50% or more.
- 19. The method of manufacturing the anisotropic conductive film according to claim 17, wherein the porous film is formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent and an amphiphilic polymer, in the atmosphere at a relative humidity of 50% or more.
 - 20. A method of manufacturing an anisotropic

conductive film, comprising the steps of:

forming a porous film consisting of polymer, having numerous holes penetrating in a film thickness direction, the holes being in a honeycomb arrangement, having inner wall surfaces which curve outwards and being filled with a conductive material; and

coating both surfaces of the porous film with an adhesive layer.

- 21. The method of manufacturing the anisotropic conductive film according to claim 20, wherein the porous film is formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent, a polymer soluble in this organic solvent, an amphiphilic material and a conductive material, in the atmosphere at a relative humidity of 50% or more.
- 22. The method of manufacturing the anisotropic conductive film according to claim 20, wherein the porous film is formed by leaving a supporting substrate on which cast is a polymer solution containing at least a hydrophobic, volatile organic solvent, an amphiphilic polymer and a conductive material, in the atmosphere at a relative humidity of 50% or more.